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APPLICATION NO.	FILING DATE	FIF	RST NAMED INVENTOR		ATTORNEY DOCKET NO.	
09/433,204	11/04/99	HAMM		R	R 12-14-9-7-5	
NAPACO A 7.77 E 0.00				EXAMINER		
MM91/0508 DOCKET ADMINISTRATOR RM 3C 512			<u>DANG, T</u>			
LUCENT TECHNOLOGIES INC			ART UNIT	PAPER NUMBER		
600 MOUNTAIN P O BOX 636 MURRAY HILL		53 6		2823 DATE MAILED	: 05/08/01	

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

Application No.

09/433,204

Applicant(s)

Hamm et al

Office Action Summary

Examiner

Art Unit



		Trung Dang	2823				
	The MAILING DATE of this communication appears	on the cover sheet with the corres	pondence addre	PSS			
A SH	for Reply ORTENED STATUTORY PERIOD FOR REPLY IS SET MAILING DATE OF THIS COMMUNICATION.	TO EXPIRE <u>one</u> MONTH	I(S) FROM				
aft - If the be - If NO co - Failur - Any r	ssions of time may be available under the provisions of 37 Ceter SIX (6) MONTHS from the mailing date of this communication period for reply specified above is less than thirty (30) days considered timely. period for reply is specified above, the maximum statutory mmunication. The to reply within the set or extended period for reply will, be reply received by the Office later than three months after the right patent term adjustment. See 37 CFR 1.704(b).	cation. s, a reply within the statutory minimur period will apply and will expire SIX (y statute, cause the application to bec	n of thirty (30) da 5) MONTHS from ome ABANDONE	the mailing date of this D (35 U.S.C. § 133).			
Status	mod patont torm adjustment. 300 07 0711 1.704(b).						
1) 🔲	Responsive to communication(s) filed on			·			
2a) 🗌	This action is FINAL . 2b) \square This ac	tion is non-final.					
3) 🗌	Since this application is in condition for allowance closed in accordance with the practice under Ex pa	· · · · · · · · · · · · · · · · · · ·		e merits is			
Disposi	tion of Claims						
4) X	Claim(s) <u>1-20</u>	is/are	e pending in the	e application.			
4	a) Of the above, claim(s)	is/ar	e withdrawn fr	om consideration.			
5) 🗌	Claim(s) is/are allowed.						
6) 🗌	Claim(s)		is/are rejected				
7) 🗆	Claim(s)		is/are objected	to.			
8) 💢	Claims <u>1-20</u>	are subject to restric	ction and/or ele	ction requirement.			
Applica	tion Papers						
9) 🗌	The specification is objected to by the Examiner.						
10)	The drawing(s) filed on is/are	e objected to by the Examiner.					
11)	☐ The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved.						
12)	The oath or declaration is objected to by the Exam	niner.					
13)	under 35 U.S.C. § 119 Acknowledgement is made of a claim for foreign $\mathfrak p$ All $\mathfrak b$ \square Some* $\mathfrak c$ \square None of:	priority under 35 U.S.C. § 119(a)	-(d).				
	1. \square Certified copies of the priority documents ha						
	2. Certified copies of the priority documents ha						
	 Copies of the certified copies of the priority of application from the International Burdee the attached detailed Office action for a list of the action for a li	eau (PCT Rule 17.2(a)).	this National S	Stage			
14)	Acknowledgement is made of a claim for domestic	priority under 35 U.S.C. § 119	(e).				
Attachm	ent(s)						
_	otice of References Cited (PTO-892)	18) Interview Summary (PTO-413) Paper	No(s).				
	otice of Draftsperson's Patent Drawing Review (PTO-948)	19) Notice of Informal Patent Application					
17) 🔲 In	formation Disclosure Statement(s) (PTO-1449) Paper No(s).	20] Other:					



Application/Control Number: 09/433,204

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1. Claim 16 generic to a plurality of disclosed patentably distinct species comprising:

Group I, claims 1-15, drawn to a method of fabricating a bipolar semiconductor from a structure in which the structure includes a base layer, an emitter layer, and a collector layer, and forming a base contact post, an emitter contact post, and a collector contact post. The process performed on the cured passivation layer is to expose the base contact post, the emitter contact post, and the collector contact post.

Group II, claims 16-20, drawn to a method of fabricating a semiconductor device wherein the process performed on a cured passivation layer is to expose at least one conductive post, not necessarily limited to a base contact post, an emitter contact post, and a collector contact post.

2. Applicant is required under 35 U.S.C. 121 to elect a single disclosed species, even though this requirement is traversed.

Should applicant traverse on the ground that the species are not patentably distinct, applicant should submit evidence or identify such evidence now of record showing the species to be obvious variants or clearly admit on the record that this is the case. In either instance, if the examiner finds one of the inventions unpatentable over the prior art, the evidence or admission may be used in a rejection under 35 U.S.C. 103(a) of the other invention.

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3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Trung Dang whose telephone number is (703) 308-2548. The examiner can normally be reached on weekdays from 9:00 AM to 5:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy, can be reached on (703) 308-4918. The fax phone number for this Group is (703) 305-3432 or (703) 308-7725.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0956.

Trung Dang

(Juny Dany

Primary Examiner, Group 2800